

## CLAIMS

- 1 1. A magnetic head comprising:  
2      a substrate;  
3      a read head being fabricated upon said substrate;  
4      a P1 pole being fabricated upon said read head;  
5      a write gap layer being fabricated upon said P1 pole;  
6      a P2 pole tip being fabricated upon portions of said write gap layer, wherein said P2 pole  
7      tip includes a first portion being comprised of a seed layer material and a second portion being  
8      comprised of electroplated material, and wherein said P2 pole tip has a width dimension W that  
9      is formed in part from a thickness of said seed layer material portion and in part from a thickness  
10     of said electroplated material portion.
- 1 2. A magnetic head as described in claim 1 wherein said first portion of said P2 pole tip that  
2      is comprised of said seed layer material forms a sidewall of said P2 pole tip.
- 1 3. A magnetic head as described in claim 1 wherein said seed layer material is formed with  
2      a thickness of approximately 50 Å to approximately 500 Å, and said electroplated material is  
3      formed with a thickness of approximately 100 Å to approximately 5000 Å.
- 1 4. A magnetic head as described in claim 3 wherein said seed layer material thickness is  
2      approximately 250 Å and said electroplated material thickness is approximately 1500 Å.

1    5.    A magnetic head as described in claim 3 wherein said seed layer material is comprised of  
2    NiFe and said electroplated material is comprised of NiFe.

*Subj 1*  
2    6.    A hard disk drive comprising:  
3         at least one hard disk being fabricated for rotary motion upon a disk drive;  
4         at least one magnetic head adapted to fly over said hard disk for writing data on said hard  
5         disk, said magnetic head including:  
6             a substrate;  
7             a read head being fabricated upon said substrate;  
8             a P1 pole being fabricated upon said read head;  
9             a write gap layer being fabricated upon said P1 pole;  
10          a P2 pole tip being fabricated upon portions of said write gap layer, wherein said P2 pole  
11         tip includes a first portion being comprised of a seed layer material and a second portion being  
12         comprised of electroplated material, and wherein said P2 pole tip has a width dimension W that  
13         is formed in part from a thickness of said seed layer material portion and in part from a thickness  
           of said electroplated material portion.

1    7.    A hard disk drive as described in claim 6 wherein said first portion of said P2 pole tip that  
2         is comprised of said seed layer material forms a sidewall of said P2 pole tip.

1    8.    A hard disk drive as described in claim 6 wherein said seed layer material is formed with  
2         a thickness of approximately 50 Å to approximately 500 Å, and said electroplated material is  
3         formed with a thickness of approximately 100 Å to approximately 5000 Å.

1 9. A hard disk drive as described in claim 8 wherein said seed layer material thickness is  
2 approximately 250 Å and said electroplated material thickness is approximately 1500 Å.

1 10. A hard disk drive as described in claim 8 wherein said seed layer material is comprised of  
2 NiFe and said electroplated material is comprised of NiFe.

1 11. A method for fabricating a magnetic head, comprising the steps of:  
2 fabricating a read head upon a substrate;  
3 fabricating a P1 pole upon said read head;  
4 fabricating a write gap layer upon said P1 pole;  
5 fabricating a block of material upon said write gap layer, said block of material having a  
6 sidewall disposed proximate a P2 pole tip location;  
7 fabricating a seed layer upon said sidewall;  
8 electroplating P2 pole tip material upon said seed layer, whereby a P2 pole tip is formed  
9 having a width W that is comprised of a thickness of said seed layer material and a thickness of  
10 said electroplated material;  
11 fabricating an induction coil proximate said P2 pole tip;  
12 fabricating a P3 pole above said induction coil in magnetic interconnection with said P2  
13 pole tip; and  
14 fabricating an encapsulation layer above said P3 pole.

1 12. A method for fabricating a magnetic head as described in claim 11 wherein said seed  
2 layer is fabricated to a thickness of approximately 50 Å to approximately 500 Å.

1    13. A method for fabricating a magnetic head as described in claim 11 wherein said  
2    electroplated material is fabricated to a thickness of approximately 100 Å to approximately 5000  
3    Å.

1    14. A method for fabricating a magnetic head as described in claim 11 wherein said seed  
2    layer is fabricated to a thickness of approximately 50 Å to approximately 500 Å, and wherein  
3    said electroplated material is fabricated to a thickness of approximately 100 Å to approximately  
4    5000 Å.

1    15. A method for fabricating a magnetic head as described in claim 14 wherein said seed  
2    layer is fabricated to a thickness of approximately 250 Å and said electroplated material is  
3    fabricated to a thickness of approximately 1500 Å.

1    16. A method for fabricating a magnetic head as described in claim 11 wherein said P2 pole  
2    tip is fabricated within a P2 pole tip trench having width that is wider than said width W of said  
3    P2 pole tip.

1    17. A method for fabricating a magnetic head as described in claim 11 wherein said block of  
2    material is removed from said write gap layer following said electroplating of said P2 pole tip  
3    material, and said P1 pole is notched in an ion milling step.

1    18. A method for fabricating a magnetic head as described in claim 14, wherein said seed  
2    layer is comprised of NiFe and said P2 pole tip material that is electroplated upon said seed layer  
3    is comprised of NiFe.

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